

**INFORMATION DISCLOSURE STATEMENT**

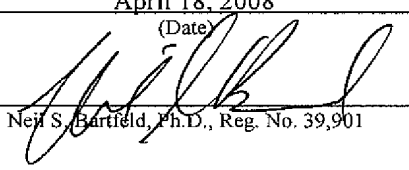
Applicant : Sato et al.  
App. No : 10/540,056  
Filed : June 22, 2005  
For : POSITIVE RESIST COMPOSITION  
AND METHOD OF FORMING RESIST  
PATTERN  
Examiner : John S Y Chu  
Art Unit : 1795

**CERTIFICATE OF EFS WEB  
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I hereby certify that this correspondence, and any other attachment noted on the automated Acknowledgement Receipt, is being transmitted from within the Pacific Time zone to the Commissioner for Patents via the EFS Web server on:

April 18, 2008

(Date)

  
Neil S. Bartfeld, Ph.D., Reg. No. 39,901

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 3 (three) references to be considered by the Examiner. Also enclosed are 2 (two) foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed before the mailing date of a final action and before the mailing date of a Notice of Allowance.

**CERTIFICATION UNDER 37 C.F.R. § 1.97(e)(1)**

I hereby certify that each item of information contained in this Statement was first cited in any communication from a foreign Patent Office in a counterpart foreign application not more than three months prior to the filing of this Information Disclosure Statement.

Thus, no fee is required as set forth in 37 C.F.R. § 1.97(c), however, the Commissioner is hereby authorized to charge any additional fees which may be required or to credit any overpayment to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 4/18/08

By: 

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